

SEARCHED

Class	Sub.	Date	Exmr.
356	399-4d	4/1/03	✓
355	53,55 69,70 71		✓
250	548		✓
430	5,20, 22,30, 311	✓	✓
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Updated APR		10/ 21 03	MV

SEARCH NOTES (INCLUDING SEARCH STRATEGY)

	Date	Exmr.
EAST <u>resistance</u> electrical &- mask, reticle, target, wafer, substrate; dose exposure, focus, defocus Sensitive indication, metrology angle, width, size.	4/1/03	✓

INTERFERENCE SEARCHED

Class	Sub.	Date	Exmr.
430	APR	10/2/03	MV

(RIGHT OUTSIDE)

BEST AVAILABLE COPY